



RECEIVED  
SEP 08 2003  
TC 1700

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Kazuyuki NITTA et al.

Serial No. 09/928,430

Filed August 14, 2001

: Confirmation No. 8121

: Docket No. 2001-1143A

: Group Art Unit 1752

: Examiner S. Lee

**POSITIVE-WORKING PHOTORESIST  
COMPOSITION AND RESIST  
PATTERNING METHOD USING SAME**

---

**RESPONSE**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

This is in response to the Official Action dated May 5, 2003, the period for response having been extended for one month by the attached Petition.